PATENT APPLICATION NO. 10/075,728 DOCKET NO. MV/L

AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions and listings of claims in the above-identified application.

Listing of Claims

Claims 1-44 (Canceled)

Claim 45 (Currently Amended) A method as claimed in claim 42, wherein said step (h) includes the subcomprising the steps of:

- a) generating with a generator electromagnetic radiation including at least one predetermined exposure wavelength that is both significantly absorbed by water and is not significantly absorbed by material composing a structure, and at least one predetermined reference wavelength that is neither significantly absorbed by water nor the material composing the structure.
- b) exposing with the generator a predetermined area of the structure with the generated electromagnetic radiation.
- c) sensing with a sensor unit at least a portion of the generated radiation from the exposed area of the structure to determine a first intensity level of the radiation at the predetermined exposure wavelength, and a second intensity level at the predetermined reference wavelength.
- d) comparing the first and second intensity levels; and
- e) determining that the predetermined area includes water if the first and second levels differ by at least a predetermined amount, and
 - a testing to confirm that the predetermined area includes water, and if water is confirmed, determining the source of the water detected by
 - i. exposing the a water-confirmed area to second electromagnetic radiation including at least one exposure wavelength that is significantly absorbed by at least one water-soluble substance and that is not significantly absorbed by material composing the structure, and at least one reference wavelength not significantly absorbed by either the water-soluble substance and or the material composing the structure;

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- ii. sensing the second electromagnetic exposed-radiation from the waterconfirmed area of the structure at the exposure wavelength absorbed by the water-soluble substance to determine a first third intensity level. at the exposure wavelength absorbed by the water soluble substance, and a second intensity level at the reference wavelength to determine a fourth intensity level;
- comparing the first third and second fourth intensity levels;
- iv. determining whether the first and second the source of water to be ground water if the third and forth intensity levels differ by at least a second predetermined amount; and determining the source of the water to be ground water if the substep (h4) indicates that the first and second levels differ by the predetermined amount or
- determining that the predetermined area includes no water if the first and second f) levels do not differ by at least the predetermined amount or if water is not confirmed by testing.
- A-The method as elaimed in of claim 45, wherein the water-soluble 46. (Currently Amended) substance includes at least one of gypsum, anhydrite, apatite, halite, sylvite, calcite, magnesite, magnesium-iron solid solution, siderite, rhodocrosite, smithsonite, dolomite, and kutnahorite.
- A-The method as claimed in of claim 45, wherein the exposure 47. (Currently Amended) wavelength includes at least one wavelength of about 6.6, 8.7, 9.6, 11.5, and 14 microns.
- A The method as claimed in of claim 45, wherein the reference 48. (Currently Amended) wavelength is in a range from 7.5 to 8.0 microns.
- 49. (Canceled)
- A The method as claimed in of claim 1845, wherein the 50. (Currently Amended) predetermined exposure and reference wavelengths are in a range from about 10-2 to about 108 microns.
- A-The method as claimed in of claim 17-45, wherein the 51. (Currently Amended) predetermined area is at least one square meter.
- A The method as claimed in of claim 17 45, wherein the structure 52. (Currently Amended) is a house.
- A The method as claimed in of claim 17.45, wherein the structure 53. (Currently Amended)

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is a building.

54. (New) The method of claim 45, prior to performance of steps a) - f), further comprising the steps of:

positioning the generator to expose the predetermined area of the structure with the electromagnetic radiation; and

positioning the sensor unit to receive and sense the portion of the generated radiation from the exposed area of the structure.

- 55. (New) The method of claim 54, wherein the generator and sensor unit are positioned so that the sensor unit receives the portion of the generated radiation from the exposed area of the structure by reflection from the exposed area.
- 56. (New) The method of claim 54, wherein the generator and sensor unit are positioned so that the sensor unit receives the portion of the generated radiation transmitted through the exposed area of the structure.
- 57. (New) The method of claim 45, wherein the generator includes a quartz halogen lamp.
- 58. (New) The method of claim 45, wherein the generator generates radiation with a power of between ten and one-thousand Watts.
- 59. (New) The method of claim 45, wherein the generator is supported in a fixed position during the performance of step b) with a photographic stand.
- 60. (New) The method of claim 45, wherein the sensor unit includes a spectrometer.
- 61. (New) The method of claim 45, wherein the sensor unit includes a spectroradiameter.
- 62. (New) The method of claim 45, wherein the sensor unit includes a hyperspectral imaging system.
- 63. (New) The method of claim 45, wherein the predetermined exposure wavelength includes at least one wavelength at about 0.76, 0.97, 1.19, 1.45, 1.94, 2.55, 2.7, 5.5 or 10.7 microns.
- 64. (New) The method of claim 45, wherein the predetermined reference wavelength includes at least one wavelength at about 1.06 or 1.66 nanometers.